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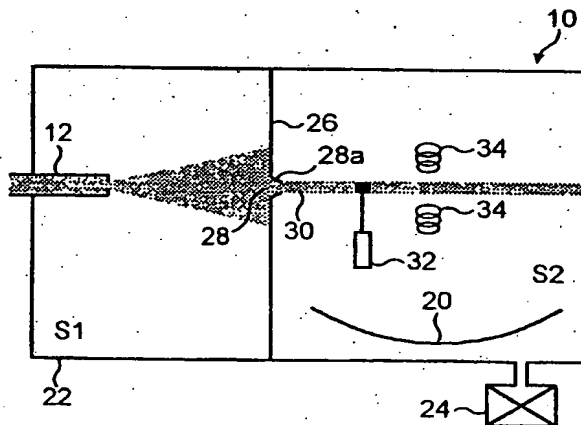
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(54) Title: **HIGH FLUX, HIGH ENERGY PHOTON SOURCE**



(57) Abstract: A high energy photon source for generating EUV radiation comprises a nozzle emitting a supersonic stream of source material, a laser or electrical/magnetic pre-ionisation mechanism and a laser or electrical/magnetic excitation mechanism and a skim plate between them providing a collimated high density beam of source material for excitation.

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